

<b>Notice of References Cited</b>	Application/Control No. 10/806,717	Applicant(s)/Patent Under Reexamination EFIMOV ET AL.	
	Examiner Ricky D. Shafer	Art Unit 2872	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-3,700,309	10-1972	Skolnick et al.	359/577
	B	US-5,162,944	11-1992	Yamamoto et al.	359/247
	C	US-5,295,016	03-1994	Van Deventer, Mattijs O.	359/347
	D	US-5,303,314	04-1994	Duling et al.	385/11
	E	US-5,400,418	03-1995	Pearson et al.	385/11
	F	US-5,867,306	02-1999	Isshiki, Kunihiro	359/337.1
	G	US-5,887,091	03-1999	Jabr et al.	385/24
	H	US-6,055,081	04-2000	Koyano et al.	398/147
	I	US-6,233,090	05-2001	Fukaishi, Kosuke	359/337
	J	US-6,175,444	01-2001	Toyohara, Atsushi	359/341.2
	K	US-6,407,861	06-2002	Zhang et al.	359/484
	L	US-6,538,815	03-2003	Cao, Simon	359/484
	M	US-6,731,836	05-2004	Takahashi et al.	385/24

**FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	JP 046324368 A	11-1994	Japan	Sakamoto et al	
	O	JP 09018417 A	01-1997	Japan	Fuji Electrochemical Co.	
	P					
	Q					
	R					
	S					
	T					

**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	
	V	
	W	
	X	

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